

**AMENDMENTS TO THE SPECIFICATION**

*Please amend the 1<sup>st</sup> paragraph of page 24 of the present specification as follows:*

Examples of the material of the thin film include metals such as aluminum, zinc, nickel, zirconium, gold, ~~silver~~, copper, tin, indium, titanium and chromium; metal oxides such as silicon oxide, aluminum oxide, magnesium oxide, and zirconium oxide; metal nitrides such as SiN, CrN, TiN and TiAlN; and materials a typical composition of which is C<sub>x</sub>H<sub>y</sub> (which may be an amorphous carbon film). Of these materials, an amorphous carbon film causes the adhesiveness thereof to the thin film to be remarkably improved.